



Applicant

Min-Lung HUANG et al.

Confirmation No: 8687

Appl. No.

10/820,855 April 9, 2004

Filed Title

Under Bump Metallization Structure Of A Semiconductor Wafer

TC/A.U.

2814

Examiner

A. Kalam

Docket No.:

: HUAN3262/REF

Customer No:

23364

AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

This is in response to the Official Action of November 16, 2006, in connection with the above-identified application. This response is timely filed.

Please amend the application as follows:

Amendments to the specification begin on page 2 of this paper.

Amendments to the claims are reflected in the listing of claims which begins on page 3 of this paper.

Remarks begin on page 7 of this paper.

